

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims, including those in the First Preliminary Amendment, in the application:

Listing of Claims:

Claim 1 (currently amended): Ultrahigh purity copper having a residual resistance ratio of 38,000 or greater and a purity of 8N or higher (~~excluding~~ ~~excluding~~ gas components of O, C, N, H, S and P) P.

Claim 2 (original): The ultrahigh purity copper according to claim 1, wherein the respective elements of O, C, N, H, S and P as gas components are 1ppm or less.

Claim 3 (currently amended): A manufacturing method of ultrahigh purity copper, wherein, upon subjecting copper to high purification with ~~the an~~ electrolytic method, an anode and a cathode are partitioned with an anion exchange membrane, an anolyte is intermittently or continuously extracted, active carbon is poured in and agitated so as to absorb ~~the~~ impurities, the impurities are removed together with the active carbon by filtration, and ~~the an~~ obtained high purity copper electrolytic solution is intermittently or continuously introduced into the cathode side and electrolyzed.

Claim 4 (canceled).

Claim 5 (new): A manufacturing method according to claim 3, wherein the ultrahigh purity copper produced by the manufacturing method has a residual resistance ratio of 38,000 or greater and a purity of 8N or higher excluding gas components of O, C, N, H, S and P.

Claim 6 (new): A manufacturing method according to claim 5, wherein the respective elements of O, C, N, H, S and P as gas components in the ultrahigh purity copper are 1ppm or less.

Claim 7 (new): An ultrahigh purity copper having a residual resistance ratio of 38,000 or greater and a purity, excluding gas components of O, C, N, H, S and P, of 8N or higher prepared by a process comprising the steps of, upon subjecting copper to high purification with an electrolytic method, partitioning an anode and a cathode with an anion exchange membrane, intermittently or continuously extracting an anolyte, pouring in and agitating active carbon to absorb impurities, removing the impurities with the active carbon by filtration, obtaining a high purity copper electrolytic solution, and intermittently or continuously introducing the solution into the cathode side and electrolyzing.

Claim 8 (new): An ultrahigh purity copper according to claim 7, wherein the respective elements of O, C, N, H, S and P as gas components are 1ppm or less.